OSA Incubator on Flat Optics: Recent Advances and Future Opportunities

26 - 28 February 2020 Washington, DC USA

HOSTED BY: Federico Capasso, Harvard University, United States Wei Ting Chen, Harvard University, United States Paulo Dainese, Corning Inc., United States

Wednesday, 26 February 2020

12:00	Lunch & Networking OSA Headquarters, 2010 Massachusetts Ave NW
13:30	Welcome Elizabeth Rogan, CEO, The Optical Society
13:45	Welcome, Goals, and General Information Federico Capasso, Harvard University, United States Paulo Dainese, Corning Inc., United States Wei Ting Chen, Harvard University, United States
14:00	Session 1: Flat Optics from Components to Systems I Flat Optics Based on Metasurfaces Federico Capasso, Harvard University, United States
	Machine-Learning Assisted Photonics: From Metasurface Device Design to Quantum Measurements Alexandra Boltasseva, Purdue University, United States
	Flat Imaging Optics Xiangang Luo, Chinese Academy of Sciences, China
15:30	Discussion Session Thomas Krauss, University of York, United Kingdom
15:45	Coffee Break

16:15	Session 2: Flat Optics from Components to Systems II	
	From Flat Optics to Flat Optical Systems Bernard Kress, Microsoft, United States	
	Flat Optics for Active Wavefront Manipulation and AR/VR Mark Brongersma, Stanford University, United States	
	Inverse Design of Large Area Metasurfaces Rahul Trivedi, Stanford University, United States	
17:45	Discussion Session Wouter Woestenborghs, PlanOpSim, Belgium	
10-00	Information & Goals for Day 2	
18:00	Welcome Dinner	
18:15	Del Sur Café, 2016 P Street NW	
Thursday, 27 February 2020		
8:00	Breakfast	
8:30	Session 3: Simulation and Optimization for Large Metasurfaces	

Global Topology Optimization of Metasurfaces Based on Machine
Learning

Jonathan Fan, Stanford University, United States

3D-Printable Multi-Layered Meta-Optics by Inverse Design
Zin Lin, Massachusetts Institute of Technology, United States

Reaching the Limits of Light-Matter Interactions Owen Miller, Yale University, United States

10:00	Discussion Session Douglas Werner, Pennsylvania State University, United States
10:15	Coffee Break
10:45	Session 4: Tunable and Multifunctional Flat Optical Devices

Active Metasurfaces – Device Concepts and Inverse Design Harry Atwater, California Institute of Technology, United States

	Solid-State Lidar with Dynamic Optical Metasurfaces Gleb Akselrod, Lumotive, United States
	Tunable Nanophotonics Devices Debashis Chanda, University of Central Florida, United States
12:15	Discussion Session Owen Miller, Yale University, United States
12:30	Lunch
13:30	Rapid-Fire Oral Presentations
	Cascaded Metasurface Optics Amir Arbabi, University of Massachusetts Amherst, United States
	Photonic Inverse Design for 3D Color Splitting Applications Gregory Roberts, California Institute of Technology, United States
	Two Metasurface Layers for Phase Gradient Imaging Hyounghan Kwon, California Institute of Technology, United States
	Computational Imaging with Dielectric Metasurfaces Shane Colburn, University of Washington, United States
	RGB-Achromatic Metalenses for a VR/AR System Zhaoyi Li, Harvard University, United States
	Infrared Metasurfaces Clara Rivero-Baleine, Lockheed Martin Corporation, United States
	Multiscale Inverse Design for Systems of Metasurface Optics Adam Backer, Sandia National Laboratories, United States
	Metasurface Holographic Projectors for Augmented Reality on Contact
	Shoufeng Lan, Texas A&M University, United States
	Additively Manufactured Freeform Gradient Index Optics James Field, Voxtel Inc., United States
14:30	Session 5: Advanced Nanofabrication for Large-Scale Flat Optics
	Large-area Fabrication of Flat Optical Components by Immersion DUV Lithography Dim Lee Kwong, A*STAR, Singapore

	Towards High-Volume Manufacturing Of Near-Infrared Metasurface Optical Devices Robert Visser, Applied Materials, United States
	Flat Optics Beyond the Wafer: Progress Towards Large Area Nanopatterned Optical Films Martin Wolk, 3M, United States
	High Volume Serial Production of Nanostructured Functional Surfaces by Roller Imprint and Injection Molding <i>Mike Bülters, Temicon GmbH, Germany</i>
16:30	Discussion Session Paulo Dainese, Corning Inc., United States
16:45	Coffee Break
17:15	Session 6: Flat Optics for AR/VR and Displays
	Metasurfaces for Waveguide AR Displays: A Case Study Pierre St. Hilaire, Magic Leap, United States
	Practicality Issues Of Metalens and Meta-Hologram Hwi Kim, Korea University, South Korea
18:15	Discussion Session Giuseppe Calafiore, Facebook Reality Labs, United States
18:30	Networking Dinner La Tomate, 1701 Connecticut Ave NW
Friday, 28 February 2	020
8:00	Breakfast
8:30	Session 7: Emerging Applications I
	Manufacturing and Applications of Wafer-Level Optics Reinhard Völkel, SUSS MicroOptics, Switzerland
	Metasurface Enabled Integrated Nanophotonic Interfaces to Quantum Systems Amit Agrawal, National Institutes of Standards and Technology,
	United States

	Aberrations and Efficiency of High-End Metalenses Wei-Ting Chen, Harvard University, United States
10:00	Discussion Session Martin Wolk, 3M, United States
10:15	Coffee Break
10:45	Session 8: Emerging Applications II
	Spatial-Division Multiplexing with Metasurfaces Paulo Dainese, Corning Inc., United States
	Optical Metasurfaces: From Lab to Product Pawel Latawiec, Metalenz, United States
11:45	Discussion Session Siavash Yazdanfar, Corning Inc., United States
12:00	Summary, Conclusions & Next Steps
12:15	Lunch
13:30	Adjournment